A SELECTIVE LOOK AT SID DISPLAY WEEK 2015

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Questions triggered by SID

What matters now in displays

Not size

What technologies are critical

Materials and processes

What might be coming

 Integration, form factors, conformability, manufacturing approaches

...and a related development

Less size, more performance



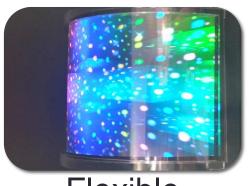
Thinner



Wider Color Gamut



Nonrectangular



Flexible



Higher Resolution

Chinese panel makers catching up

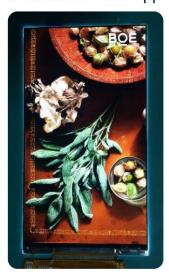
110" 8K4K



4.7 UHD LTPS 941 ppi



5.5 UHD LTPS 800+ ppi



5.5 FHD 100% NTSC



BOE talking about avoiding commoditization by moving up performance curve, not down price curve

Some things haven't changed!



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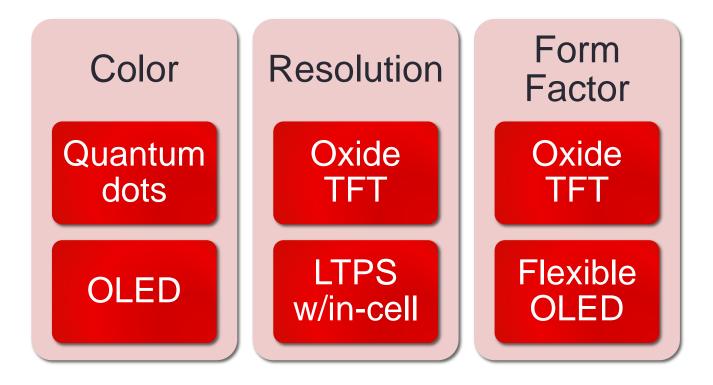
Materials and processes

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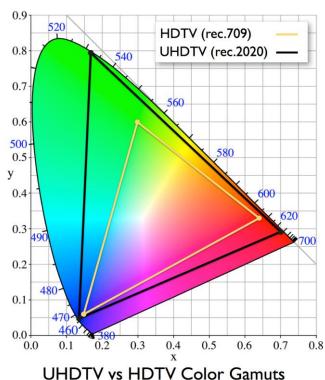
Ways to get to better performance



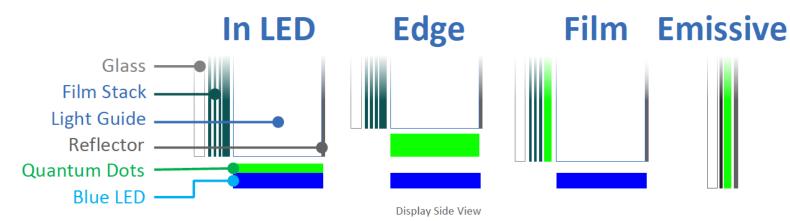
High levels of activity (papers, demos) around QD and oxide

Quantum dots

Rec. 2020 represents an expansion in color gamut, which quantum dots are well-positioned to make happen – soon!



Multiple ways QDs can impact the LCD stack



Jason Hartlove, Nanosys, Investors Conference

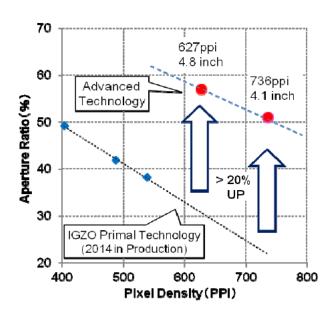
Why oxide

TFT characteristics	a-Si	oxide	LTPS
Mobility (cm ² /V-s)	<1	1-30	30-100
Uniformity	good	good	ok
Reliability	poor	good	good
V _{th} shift	>30	<1	<0.5
Mask steps	4 - 6 (7 for OLED)	4 - 6	5 - 9
Pixel circuit (OLED)	4T + 2C	2T + 1C	5T + 2C
Process temp (°C)	150 - 350	450	250 - 550
Generation	>10	8.5	6.5 - 8.5
Cost/Yield	low/high	low/high	high/low

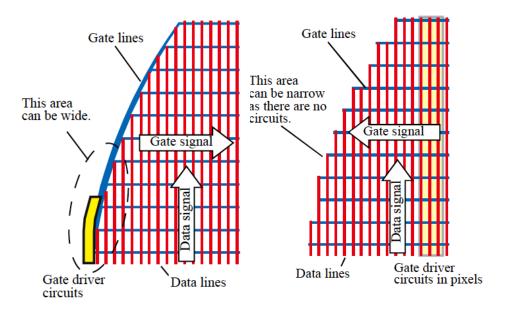
Adapted from Toshio Kamiya, Short Course S-3

Why oxide

Good aperture ratio at very high resolution, enabled by transparency of oxide semiconductors



Why oxide



High mobility enables integration of gate drivers, eliminating bezel

Sharp (59.1)



OLED + oxide

18 inch WXGA AMOLED (IGZO) 0.18 mm thick; bend radius: 30 mm



LGD (65.1)

OLED + oxide

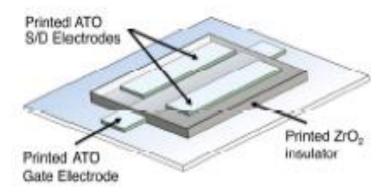
13.3 inch 8K (664 ppi) using CAAC-IGZO



Advanced Film Device/ Semiconductor Energy Laboratory (63.3)

Oxide: printed inorganic TFTs?

Antimony tin oxide and zirconium dioxide in sol-gel to create "inks" TFTs inkjet-printed



But a-Si, LTPS not slowing down

3.5 inch VGA a-Si AHVA LCD on plastic



AUO (9.3)

8 inch 4K, incell touch

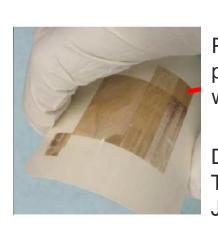


JDI (63.2)

55 inch 8K (7680x4320) 120 Hz a-Si IPS



Panasonic (72.1)



Polysilicon TFTs produced at 150°C w/liquid silicon ink

Delft Univ. of Technology, JAIST (29.1)

+ 512 PPI 0.9mm

4.3 inch FHD LTPS,

0.9 mm thick

AUO (4.3)

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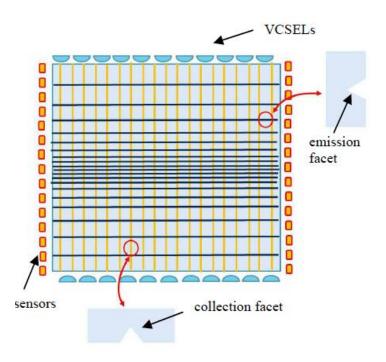
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3D user interface

Surface, air detection; multitouch; gesture recognition; finger/stylus







Qualcomm (74.2)

Integrating micro LEDs and TFTs

ASSEMBLY - CHIP LEVEL



GROWTH - WAFER LEVEL

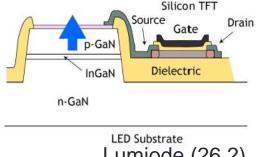
EPITAXIAL LED SILICON CMOS THIN FILM TRANSISTORS **LED ARRAY**

Wafer bonding/ flip-chip: limited density

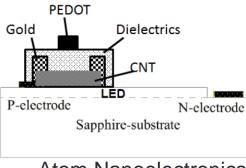
Build LED array, deposit a-Si thin film, laser crystallize to form TFTs

Print SWCNT TFT backplane on top of LED array

Build 3D stack of red, green, blue LEDs on top of CMOS



Lumiode (26.2)

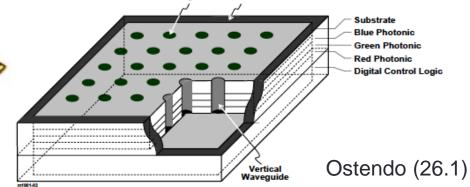


Atom Nanoelectronics

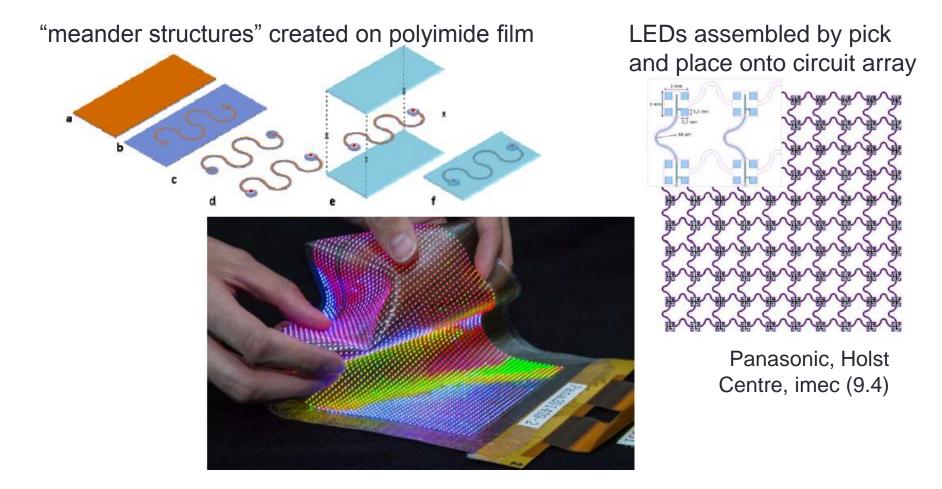
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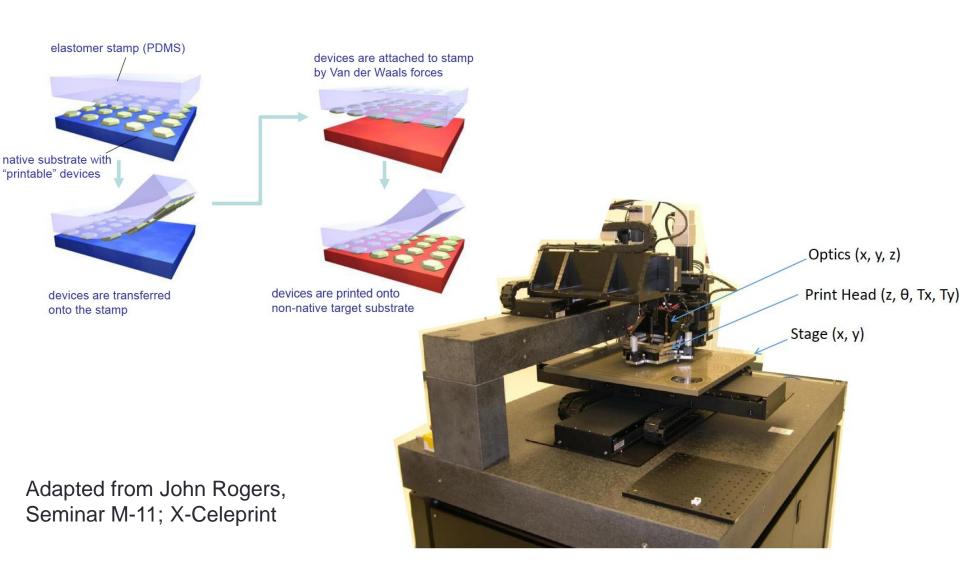


Beyond flexibility: stretchability



Also, Bao group at Stanford (9.1), others investigating strechable polymer and CNT TFTs

A new manufacturing approach?



Re-starting manufacturing in the US?

National Network for Manufacturing Innovation (so far)



Coming Soon:

http://manufacturing.gov/

Flexible Hybrid Electronics
Integrated Photonics
Clean Energy
Revolutionary Fibers and Textiles

THANK YOU

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